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MS ISSUE FEE  
PATENT  
0171-1079PUS1

IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant: Hiroki YOSHIKAWA et al. Art Unit: 1756  
Application No.: 10/811,924 Examiner: Stephen D. Rosasco  
Filed: March 30, 2004 Conf.: 3156  
For: PHOTOMASK BLANK, PHOTOMASK, AND METHOD OF MANUFACTURE

**LETTER REQUESTING INITIALED PTO/SB/08 FORM**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

NOV 16 2007

Sir:

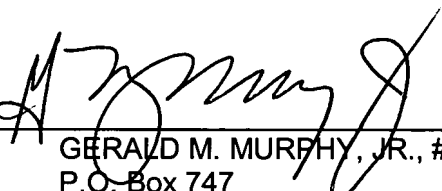
In reviewing the above-captioned application file upon allowance, the undersigned has noted that acknowledgement was not received for the PTO/SB/08 Form filed with the Information Disclosure Statement on September 10, 2007.

Accordingly, a copy of the unacknowledged PTO/SB/08 Form is attached hereto. The Examiner is respectfully requested to return the initialed form to the undersigned as soon as possible.

If necessary, the Commissioner is hereby authorized in this, concurrent, and future replies, to charge payment or credit any overpayment to Deposit Account No. 02-2448 for any additional fees required under 37 C.F.R. §1.16 or under 37 C.F.R. §1.17; particularly, extension of time fees.

Respectfully submitted,

BIRCH, STEWART, KOLASCH & BIRCH, LLP

By   
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